

PATENT APPLICATION

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 2851**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Naomasa SHIRAISHI

Group Art Unit: 2851

Application No.: 10/679,151

Examiner: A. MATHEWS

Filed: October 6, 2003

Docket No.: 032136.09

For: PROJECTION EXPOSURE METHOD WITH LUMINOUS FLUX DISTRIBUTION

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the March 22, 2007 Office Action, the shortened statutory period for reply being extended by the attached Petition for Extension of Time, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.